NOTES:

- 1. SUBSTRATE: Fused Silica
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN <3 arcmin
- PARTS TO THIS DRAWING



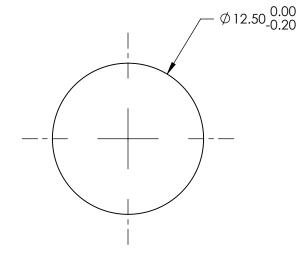
\$1: R(abs) >99% @ 248nm

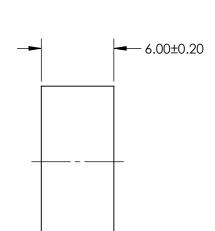
S2: NONE



5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS APPLY ACROSS CLEAR APERTURE

6. ROHS COMPLIANT





SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

	\$1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	10-5	N/A
SURFACE FLATNESS	λ/10	N/A
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION	$\phi \lhd$	TITLE
ALL DIMS IN	mm	DWG

Ec	lmund	Op	otics®

12.5mm 248nm 45°, EXCIMER Laser Line Mirror

1011	IN	mm	DWG NO	47984	SHEET 1 OF 1
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